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PATENT  
1691-0170P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: WAKAMATSU, Satoru et al.

Int'l. Appl. No.: PCT/JP01/03865

Appl. No.: New Group:

Filed: January 11, 2002 Examiner:

For: POLYCRYSTALLINE SILICON, METHOD AND  
APPARATUS FOR PRODUCING THE SAME

PRELIMINARY AMENDMENT

**BOX PATENT APPLICATION**

Assistant Commissioner for Patents  
Washington, DC 20231

January 11, 2002

Sir:

The following Preliminary Amendments and Remarks are respectfully submitted in connection with the above-identified application.

AMENDMENTS

IN THE SPECIFICATION:

Please amend the specification as follows:

Before line 1, insert --This application is the national phase under 35 U.S.C. § 371 of PCT International Application No. PCT/JP01/03865 which has an International filing date of May 9, 2001, which designated the United States of America.--

REMARKS

The specification has been amended to provide a cross-reference to the previously filed International Application.

Entry of the above amendments is earnestly solicited. An early and favorable first action on the merits is earnestly solicited.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fees required under 37 C.F.R. § 1.16 or under 37 C.F.R. § 1.17; particularly, extension of time fees.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP

By Mark S. Weiner #36,623  
Mark S. Weiner, #32,181

MSW/rem  
1691-0170P

P.O. Box 747  
Falls Church, VA 22040-0747  
(703) 205-8000